

L Number	Hits	Search Text	DB	Time stamp
1	4	(("5756391") or ("6261908") or ("6297144") or ("6335250").PN. selectively with implant\$3 with (Si or silicon)	USPAT; US-PGPUB	2004/06/23 07:19
2	1038		USPAT; US-PGPUB	2004/06/23 07:28
3	1126707	Co or cobalt	USPAT; US-PGPUB	2004/06/23 07:28
4	6	(selectively with implant\$3 with (Si or silicon)) with (Co or cobalt)	USPAT; US-PGPUB	2004/06/23 07:27
5	138946	@ad>20030110 or @rlad>20030110	USPAT; US-PGPUB	2004/06/23 07:27
6	5	((selectively with implant\$3 with (Si or silicon)) with (Co or cobalt) not (@ad>20030110 or @rlad>20030110)	USPAT; US-PGPUB	2004/06/23 07:27
7	3614	selectively and implant\$3 and (Si or silicon)	EPO; JPO; DERWENT; IBM_TDB	2004/06/23 07:28
8	5618586	Co or cobalt	EPO; JPO; DERWENT; IBM_TDB	2004/06/23 07:28
9	743	(selectively and implant\$3 and (Si or silicon)) and (Co or cobalt)	EPO; JPO; DERWENT; IBM_TDB	2004/06/23 07:28
10	1064880	semiconductor or "integrated circuit"	EPO; JPO; DERWENT; IBM_TDB	2004/06/23 07:29
11	561	((selectively and implant\$3 and (Si or silicon)) and (Co or cobalt)) and (semiconductor or "integrated circuit")	EPO; JPO; DERWENT; IBM_TDB	2004/06/23 07:30
12	22606	silicide or silicidizing	EPO; JPO; DERWENT; IBM_TDB	2004/06/23 07:30
13	62	((selectively and implant\$3 and (Si or silicon)) and (Co or cobalt)) and (semiconductor or "integrated circuit")) and (silicide or silicidizing )	EPO; JPO; DERWENT; IBM_TDB	2004/06/23 07:30
-	628	438/683.ccis.	USPAT; US-PGPUB	2004/06/22 11:54
-	362	438/683.ccis. and (Co or cobalt)	USPAT; US-PGPUB	2004/06/22 10:58
-	357	(438/683.ccis. and (Co or cobalt)) not (@ad>20030110 or @rlad>20030110)	USPAT; US-PGPUB	2004/06/22 11:03
-	19170	implant\$3 with (Si or silicon)	USPAT; US-PGPUB	2004/06/23 07:26
-	103	((438/683.ccis. and (Co or cobalt)) not (@ad>20030110 or @rlad>20030110)) and (implant\$3 with (Si or silicon))	USPAT; US-PGPUB	2004/06/22 11:03
-	490	438/682.ccis.	USPAT; US-PGPUB	2004/06/22 11:55
-	355	(Co or cobalt) and 438/682.ccis.	USPAT; US-PGPUB	2004/06/22 11:55
-	210	"high melting-point metal"	USPAT; US-PGPUB	2004/06/22 11:55
-	1	438/682.ccis. and "high melting-point metal"	USPAT; US-PGPUB	2004/06/22 11:55
-	346	((Co or cobalt) and 438/682.ccis.) not (@ad>20030110 or @rlad>20030110)	USPAT; US-PGPUB	2004/06/22 11:56
-	314	((Co or cobalt) and 438/682.ccis.) not (@ad>20030110 or @rlad>20030110) not ((438/683.ccis. and (Co or cobalt)) not (@ad>20030110 or @rlad>20030110)) and (implant\$3 with (Si or silicon)))	USPAT; US-PGPUB	2004/06/22 11:57
-	73	(implant\$3 with (Si or silicon)) and (((Co or cobalt) and 438/682.ccis.) not (@ad>20030110 or @rlad>20030110)) not (((438/683.ccis. and (Co or cobalt)) not (@ad>20030110 or @rlad>20030110)) and (implant\$3 with (Si or silicon))))	USPAT; US-PGPUB	2004/06/22 11:57
-	1	("5940726").PN.	USPAT; US-PGPUB	2004/06/23 07:19